

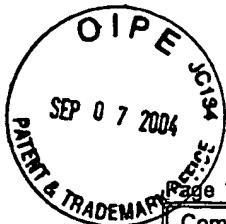
Comparable to Form PTO-1449		U.S. Department of Commerce Patent & Trademark Office		Atty. Docket No. N9350 Customer No. 23456		Serial No. 10/657,477	
<p style="text-align: center;">INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)</p> <p style="text-align: right;">OCT 16 2004 U.S. PATENT & TRADEMARK OFFICE</p>							
<p style="text-align: center;">Applicant</p> <p style="text-align: center;">Henry E. Juszkiewicz et al.</p>							
<p style="text-align: center;">Filing Date Sept. 8, 2003 Group 2837</p>							
Examiner Initial		Document No.	Date	Name	Class	Subclass	Filing Date If Appropriate
JD		4,336,734	Jun. 29, 1982	Polson	84	1.01	
JD		4,437,377	Mar. 20, 1984	Mitarai et al.	84	1.01	
JD		4,603,321	Jul. 29, 1986	Gutman et al.	340	347	
JD		4,805,510	Feb. 21, 1989	De Dianous	84	1.16	
JD		4,817,484	Apr. 4, 1989	Iba et al.	84	1.16	
JD		5,079,984	Jan. 14, 1992	Kosugi et al.	84	645	
JD		5,270,475	Dec. 14, 1993	Weiss et al.	84	603	
JD		5,308,916	May 3, 1994	Murata et al.	84	603	
JD		5,367,117	Nov. 22, 1994	Kikuchi	84	603	
JD		5,789,689	Aug. 4, 1998	Doidic et al.	84	603	
JD		5,837,912	Nov. 17, 1998	Eagen	84	267	
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JD		6,191,350	Feb. 20, 2001	Okulov et al.	84	646	
JD		6,281,830	Aug. 28, 2001	Flety	341	155	
JD		6,787,690	Sep. 7, 2004	Celi et al.	84	723	
FOREIGN DOCUMENTS							
MISCELLANEOUS DOCUMENTS							
<i>JD</i>		US2003/0159570	Aug. 28, 2003	Toshitani	84	645	
Examiner: <i>/Jeffrey Donels/</i>				Date Considered 01/22/2007			
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